# Standard Products QCOTS<sup>TM</sup> UT9Q512K32 16Megabit SRAM MCM

Data Sheet

June, 2003



## FEATURES

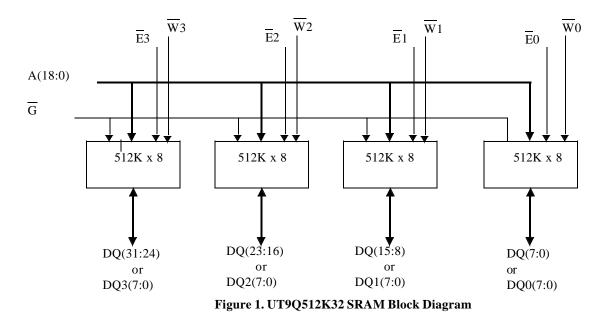
- □ 25ns maximum (5 volt supply) address access time
- □ Asynchronous operation for compatible with industry standard 512K x 8 SRAMs
- □ TTL compatible inputs and output levels, three-state bidirectional data bus
- **Typical radiation performance** 
  - Total dose: 50krads
  - SEL Immune >80 MeV-cm<sup>2</sup>/mg
  - $LET_{TH}(0.25) = >10 \text{ MeV-cm}^2/\text{mg}$
  - Saturated Cross Section (cm<sup>2</sup>) per bit, 5.0E-9
     ≤1E-8 errors/bit-day, Adams 90% geosynchronous heavy ion
- Packaging options:
   68-lead dual cavity cert
  - 68-lead dual cavity ceramic quad flatpack (CQFP) (weight 7.37 grams)
- Standard Microcircuit Drawing 5962-01511
   QML T and Q compliant part

# INTRODUCTION

The QCOTS<sup>TM</sup> UT9Q512K32 Quantified Commercial Off-the-Shelf product is a high-performance 2M byte (16Mbit) CMOS static RAM multi-chip module (MCM), organized as four individual 524,288 x 8 bit SRAMs with a common output enable. Memory expansion is provided by an active LOW chip enable ( $\overline{En}$ ), an active LOW output enable ( $\overline{G}$ ), and three-state drivers. This device has a powerdown feature that reduces power consumption by more than 90% when deselected.

Writing to each memory is accomplished by taking chip enable (En) input LOW and write enable (Wn) inputs LOW. Data on the eight I/O pins (DQ<sub>0</sub> through DQ<sub>7</sub>) is then written into the location specified on the address pins (A<sub>0</sub> through A<sub>18</sub>). Reading from the device is accomplished by taking chip enable (En) and output enable (G) LOW while forcing write enable (Wn) HIGH. Under these conditions, the contents of the memory location specified by the address pins will appear on the I/O pins.

The input/output pins are placed in a high impedance state when the device is deselected (En HIGH), the outputs are disabled ( $\overline{G}$  HIGH), or during a write operation (En LOW and  $\overline{Wn}$  LOW). Perform 8, 16, 24 or 32 bit accesses by making  $\overline{Wn}$  along with En a common input to any combination of the discrete memory die.



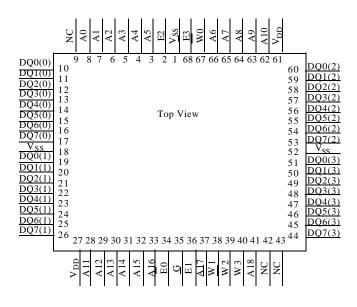


Figure 2. 25ns SRAM Pinout (68)

### **PIN NAMES**

A(18:0)	Address	Wn	Write Enable
DQn(7:0)	Data Input/Output	G	Output Enable
En	Enable	V <sub>DD</sub>	Power
		V <sub>SS</sub>	Ground

#### **DEVICE OPERATION**

The UT9Q512 has three control inputs called Enable 1 ( $\overline{En}$ ), Write Enable ( $\overline{Wn}$ ), and Output Enable ( $\overline{G}$ ); 19 address inputs, A(18:0); and eight bidirectional data lines, DQ(7:0). En Device Enable controls device selection, active, and standby modes. Asserting  $\overline{En}$  enables the device, causes  $I_{DD}$  to rise to its active value, and decodes the <u>19</u> address inputs to select one of 524,288 words in the memory. Wn controls read and write operations. During a read cycle,  $\overline{G}$  must be asserted to enable the outputs.

Table 1. Device (	Operation	Truth	Table
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G	Wn	En	I/O Mode	Mode
$\mathbf{X}^{1}$	Х	1	3-state	Standby
Х	0	0	Data in	Write
1	1	0	3-state	Read <sup>2</sup>
0	1	0	Data out	Read

Notes:

1. "X" is defined as a "don't care" condition.

2. Device active; outputs disabled.

### READ CYCLE

A combination of  $\overline{W}n$  greater than  $V_{IH}$  (min) and  $\overline{E}n$  less than  $V_{IL}$  (max) defines a read cycle. Read access time is measured from the latter of DeviceEnable, Output Enable, or valid address to valid data output.

SRAM Read Cycle 1, the Address Access in figure 3a, is initiated by a change in address inputs while the chip is enabled with  $\overline{G}$  asserted and  $\overline{W}n$  deasserted. Valid data appears on data outputs DQ(7:0) after the specified t<sub>AVQV</sub> is satisfied. Outputs remain active throughout the entire cycle. As long as Device Enable and Output Enable are active, the address inputs may change at a rate equal to the minimum read cycle time (t<sub>AVAV</sub>).

SRAM read Cycle 2, the Chip Enable - Controlled Access in figure 3b, is initiated by En going active while  $\overline{G}$  remains asserted,  $\overline{W}n$  remains deasserted, and the addresses remain stable for the entire cycle. After the specified t<sub>ETQV</sub> is satisfied, the eight-bit word addressed by A(18:0) is accessed and appears at the data outputs DQ(7:0).

SRAM read Cycle 3, the Output Enable - Controlled Access in figure 3c, is initiated by  $\overline{G}$  going active while  $\overline{En}$  is asserted,  $\overline{Wn}$  is deasserted, and the addresses are stable. Read access time is  $t_{GLOV}$  unless  $t_{AVOV}$  or  $t_{ETOV}$  have not been satisfied.

### WRITE CYCLE

A combination of  $\overline{W}n$  less than  $V_{IL}(max)$  and  $\overline{E}n$  less than  $V_{IL}(max)$  defines a write cycle. The state of  $\overline{G}$  is a "don't care" for a write cycle. The outputs are placed in the high-impedance state when either  $\overline{G}$  is greater than  $V_{IH}(min)$ , or when  $\overline{W}n$  is less than  $V_{IL}(max)$ .

Write Cycle 1, the Write Enable-controlled Access is defined by a write terminated by Wn going high, with En still active. The write pulse width is defined by  $t_{WLWH}$  when the write is initiated by Wn, and by  $t_{ETWH}$  when the write is initiated by En. Unless the outputs have been previously placed in the highimpedance state by G, the user must wait  $t_{WLQZ}$  before applying data to the nine bidirectional pins DQ(7:0) to avoid bus contention.

Write Cycle 2, the Chip Enable-controlled Access is defined by a write terminated by the latter of  $\overline{En}$  going inactive. The write pulse width is defined by  $t_{WLEF}$  when the write is initiated by  $\overline{Wn}$ , and by  $t_{\overline{ETEF}}$  when the write is initiated by the  $\overline{En}$  going active. For the  $\overline{Wn}$  initiated write, unless the outputs have been previously placed in the high-impedance state by  $\overline{G}$ , the user must wait  $t_{WLQZ}$  before applying data to the eight bidirectional pins DQ(7:0) to avoid bus contention.

#### TYPICAL RADIATION HARDNESS

The UT9Q512K32 SRAM incorporates features which allows operation in a limited radiation environment.

Table 2. Radiation HardnessDesign Specifications1

Total Dose	50	krad(Si)
Heavy Ion Error Rate <sup>2</sup>	<1E-8	Errors/Bit-Day

Notes:

2. 00% worst case particle environment, Geosynchronous orbit, 100 mils of Aluminum.

The SRAM will not latchup during radiation exposure under recommended operating conditions.

# ABSOLUTE MAXIMUM RATINGS<sup>1</sup>

(Referenced to  $V_{SS}$ )

SYMBOL	PARAMETER	LIMITS
V <sub>DD</sub>	DC supply voltage	-0.5 to 7.0V
V <sub>I/O</sub>	Voltage on any pin	-0.5 to 7.0V
T <sub>STG</sub>	Storage temperature	-65 to +150°C
P <sub>D</sub>	Maximum power dissipation	1.0W (per byte)
T <sub>J</sub>	Maximum junction temperature <sup>2</sup>	+150°C
$\Theta_{\rm JC}$	Thermal resistance, junction-to-case <sup>3</sup>	10°C/W
II	DC input current	±10 mA

Notes:

Stresses outside the listed absolute maximum ratings may cause permanent damage to the device. This is a stress rating only, and functional operation of the device at these or any other conditions beyond limits indicated in the operational sections of this specification is not recommended. Exposure to absolute maximum rating conditions for extended periods may affect device reliability and performance.
 Maximum junction temperature may be increased to +175°C during burn-in and steady-static life.
 Test per MIL-STD-883, Method 1012.

### **RECOMMENDED OPERATING CONDITIONS**

SYMBOL	PARAMETER	LIMITS
V <sub>DD</sub>	Positive supply voltage	4.5 to 5.5V
T <sub>C</sub>	Case temperature range	-40 to +125°C
V <sub>IN</sub>	DC input voltage	0V to V <sub>DD</sub>

# DC ELECTRICAL CHARACTERISTICS (Pre/Post-Radiation)\*

SYMBOL PARAMETER CONDITION MIN MAX 2.0 V<sub>IH</sub> High-level input voltage V<sub>IL</sub> Low-level input voltage 0.8 0.4 V<sub>OL1</sub> Low-level output voltage  $I_{OL} = 8mA, V_{DD} = 4.5V$  $I_{OL} = 200 \mu A, V_{DD} = 4.5 V$ Low-level output voltage 0.08 V<sub>OL2</sub>  $I_{OH} = -4mA, V_{DD} = 4.5V$ 2.4 V<sub>OH1</sub> High-level output voltage  $I_{OH} = 200 \mu A, V_{DD} = 4.5 V$ V<sub>OH2</sub> High-level output voltage 3.0 f = 1MHz @ 0V  $C_{I\!N}{}^1$ 32 Input capacitance Bidirectional I/O capacitance f = 1MHz @ 0V 16  $C_{IO}^{1}$  $V_{IN} = V_{DD}$  and  $V_{SS}$ ,  $V_{DD} = V_{DD}$  (max) Input leakage current -2 2  $I_{IN}$ -2 2  $V_{O} = V_{DD}$  and  $V_{SS}$ Three-state output leakage current I<sub>OZ</sub>  $V_{DD} = V_{DD} \ (max)$  $\overline{G} = V_{DD} (max)$  $V_{DD} = V_{DD}$  (max),  $V_{O} = V_{DD}$ -90  $I_{0S}^{2,3}$ 90 Short-circuit output current  $V_{DD} = V_{DD} \text{ (max), } V_0 = 0V$ Supply current operating Inputs:  $V_{IL} = 0.8V$ , 125  $I_{DD}(OP)$ @ 1MHz  $V_{IH} = 2.0V$ (per byte)  $I_{OUT} = 0mA$  $V_{DD} = V_{DD} (max)$ Inputs:  $V_{IL} = 0.8V$ ,  $I_{DD1}(OP)$ Supply current operating 180 @40MHz  $V_{IH} = 2.0V$ (per byte)  $I_{OUT} = 0mA$  $V_{DD} = V_{DD} (max)$ Inputs:  $V_{IL} = V_{SS}$ -40°C and  $I_{DD2}(SB)$ Supply current standby 6 25°C @0MHz  $I_{OUT} = 0mA$ (per byte)  $\overline{\text{E1}} = \text{V}_{\text{DD}} - 0.5, \text{ V}_{\text{DD}} = \text{V}_{\text{DD}} \text{ (max)}$ 125°C 12  $V_{IH} = V_{DD} - 0.5V$ 

UNIT

V

V

V

V

V

V

pF

pF

μΑ

μΑ

mA

mA

mA

mA

mA

 $(-40^{\circ}\text{C to} + 125^{\circ}\text{C}) (\text{V}_{\text{DD}} = 5.0\text{V} \pm 10\%)$ 

Notes:

\* Post-radiation performance guaranteed at 25°C per MIL-STD-883 Method 1019.

1. Measured only for initial qualification and after process or design changes that could affect input/output capacitance.

2. Supplied as a design limit but not guaranteed or tested.

3. Not more than one output may be shorted at a time for maximum duration of one second.

# AC CHARACTERISTICS READ CYCLE (Pre/Post-Radiation)\*

(-40°C to +125°C) ( $V_{DD} = 5.0V \pm 10\%$ )

SYMBOL	PARAMETER	MIN	MAX	UNIT
t <sub>AVAV</sub> <sup>1</sup>	Read cycle time	25		ns
t <sub>AVQV</sub>	Read access time		25	ns
t <sub>AXQX</sub> <sup>2</sup>	Output hold time	3		ns
t <sub>GLQX</sub> <sup>2</sup>	G-controlled Output Enable time	3		ns
t <sub>GLQV</sub>	G-controlled Output Enable time (Read Cycle 3)		10	ns
t <sub>GHQZ</sub> <sup>2</sup>	G-controlled output three-state time		10	ns
t <sub>ETQX</sub> <sup>2,3</sup>	En-controlled Output Enable time	3		ns
t <sub>ETQV</sub> <sup>3</sup>	En-controlled access time		25	ns
$t_{\rm EFQZ}^{1,2,4}$	En-controlled output three-state time		10	ns

Notes: \* Post-radiation performance guaranteed at 25 °C per MIL-STD-883 Method 1019.

Functional test.
 Three-state is defined as a 500mV change from steady-state output voltage.
 The ET (enable true) notation refers to the falling edge of En. SEU immunity does not affect the read parameters.
 The EF (enable false) notation refers to the rising edge of En. SEU immunity does not affect the read parameters.

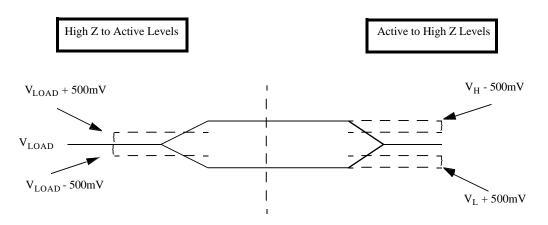


Figure 3. 5-Volt SRAM Loading

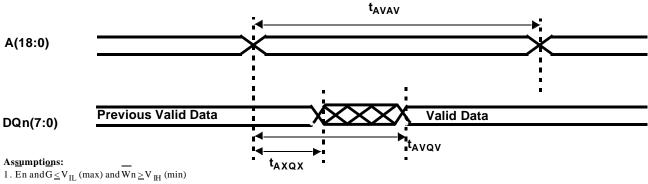
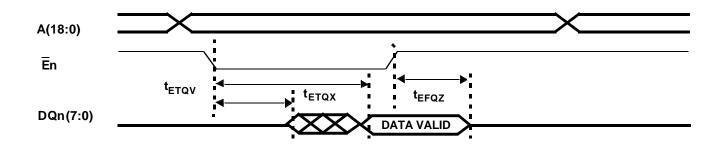
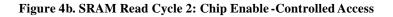


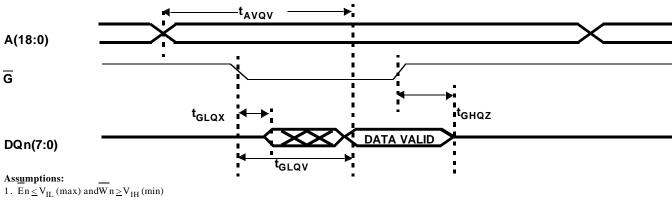


Figure 4a. SRAM Read Cycle 1: Address Access



 $\begin{array}{l} \textbf{Assumptions:} \\ 1. \ G \leq V_{IL} \ (max) \ \text{and} \ \overline{Wn} \geq V_{IH} \ (min) \end{array}$ 





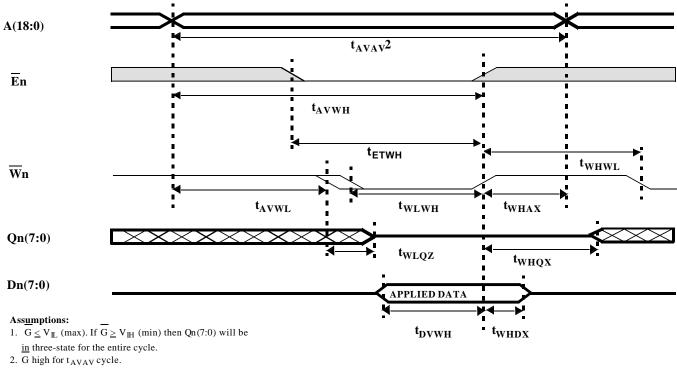


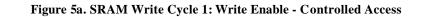
# AC CHARACTERISTICS WRITE CYCLE (Pre/Post-Radiation)\*

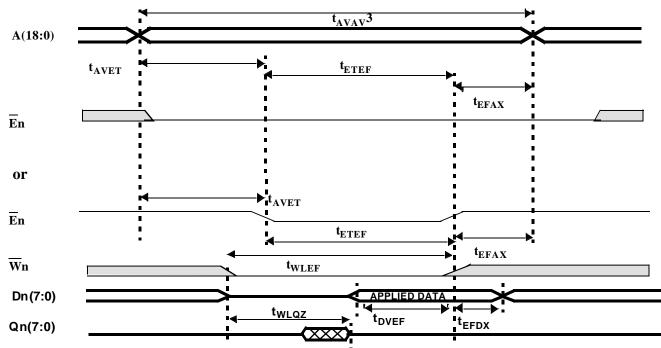
 $(-40^{\circ}\text{C to} + 125^{\circ}\text{C}) (\text{V}_{\text{DD}} = 5.0\text{V} \pm 10\%)$ 

SYMBOL	PARAMETER	MIN	MAX	UNIT
t <sub>AVAV</sub> <sup>1</sup>	Write cycle time	25		ns
t <sub>ETWH</sub>	Device Enable to end of write	20		ns
t <sub>AVET</sub>	Address setup time for write (En - controlled)	1		ns
t <sub>AVWL</sub>	Address setup time for write $(\overline{W}n - controlled)$	0		ns
t <sub>WLWH</sub>	Write pulse width	20		ns
t <sub>WHAX</sub>	Address hold time for write ( $\overline{W}n$ - controlled)	0		ns
t <sub>EFAX</sub>	Address hold time for Device Enable (En - controlled)	0		ns
t <sub>WLQZ</sub> <sup>2</sup>	$\overline{W}n$ - controlled three-state time		10	ns
t <sub>WHQX</sub> <sup>2</sup>	Wn - controlled Output Enable time	5		ns
t <sub>ETEF</sub>	Device Enable pulse width ( $\overline{En}$ - controlled)	20		ns
t <sub>DVWH</sub>	Data setup time	15		ns
t <sub>WHDX</sub>	Data hold time	0		ns
t <sub>WLEF</sub>	Device Enable controlled write pulse width	20		ns
t <sub>DVEF</sub>	Data setup time	15		ns
t <sub>EFDX</sub>	Data hold time	0		ns
t <sub>AVWH</sub>	Address valid to end of write	20		ns
t <sub>WHWL</sub> <sup>1</sup>	Write disable time	5		ns

Notes:
\* Post-radiation performance guaranteed at 25 °C per MIL-STD-883 Method 1019.
1. Functional test performed with outputs disabled (G high).
2. Three-state is defined as 500mV change from steady-state output voltage.





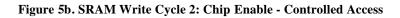


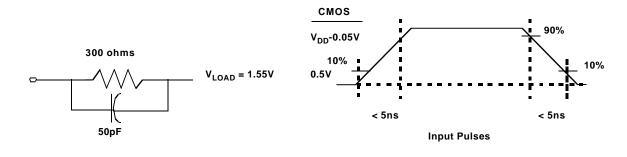
Assumptions & Notes:

1. G  $\leq$  V IL (max). If G  $\geq$  V IH (min) then Qn(7:0) will be in three-state for the entire cycle.

2<u>. Ei</u>ther En scenario above can occur.

 $3.\overline{G}$  high for  $t_{AVAV}$  cycle.





#### Notes:

1. 50pF including scope probe and test socket capacitance.

2. Measurement of data output occurs at the low to high or high to low transition mid-point

(i.e., CMOS input =  $V_{DD}/2$ ).

### Figure 6. AC Test Loads and Input Waveforms

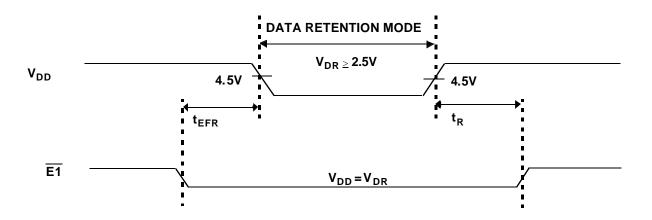


Figure 7. Low  $V_{\mbox{\scriptsize DD}}$  Data Retention Waveform

### DATA RETENTION CHARACTERISTICS (Pre/Post-Irradiation)

SYMBOL	PARAMETER	MINIMUM	MAXIMUM	UNIT
V <sub>DR</sub>	V <sub>DD</sub> for data retention	2.5		V
I <sub>DDR</sub> <sup>1,2</sup>	Data retention current (per byte)		5.0	mA
t <sub>EFR</sub> <sup>1,3</sup>	Chip deselect to data retention time	0		ns
$t_{R}^{1,3}$	Operation recovery time	t <sub>AVAV</sub>		Ns

Notes:

1. En =  $V_{DD}$ - .2V, all other inputs =  $V_{DR}$  or  $V_{SS}$ .

2. Data retention current ( $I_{DDR}$ ) Tc = 25°C.

3. Not guaranteed or tested.

4.  $V_{DR} = T = -40^{\circ}C$  and  $125^{\circ}C$ .

# DATA RETENTION CHARACTERISTICS (Pre/Post-Irradiation)

# (10 Second Data Retention Test, $T_C$ =-40°C and +125°C)

SYMBOL	PARAMETER	MINIMUM	MAXIMUM	UNIT
V <sub>DD</sub> <sup>1</sup>	V <sub>DD</sub> for data retention	4.5	5.5	V
t <sub>EFR</sub> <sup>2, 3</sup>	Chip select to data retention time	0		ns
$t_{R}^{2,3}$	Operation recovery time	t <sub>AVAV</sub>		ns

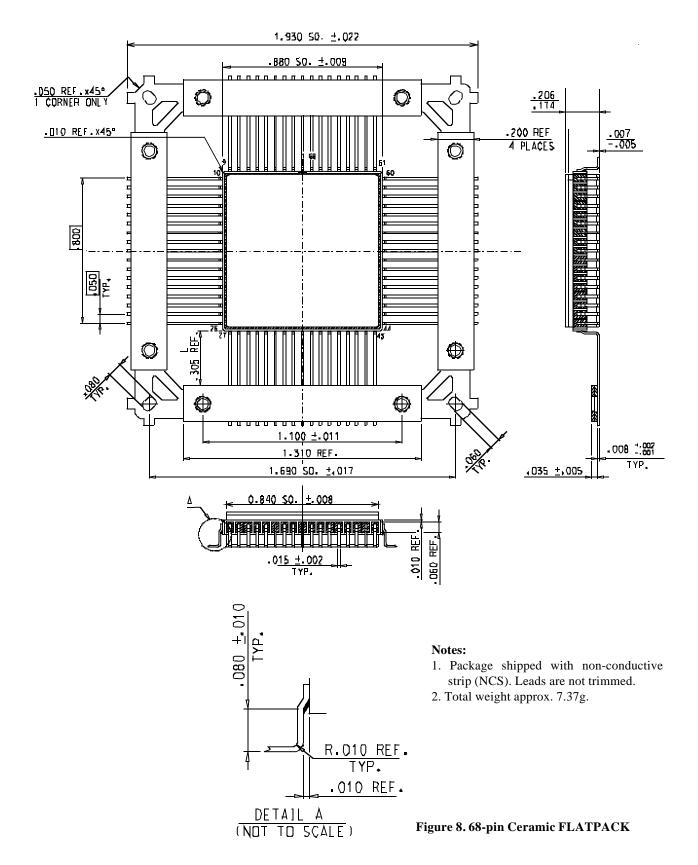
Notes:

1. Performed at  $V_{DD}$  (min) and  $V_{DD}$  (max).

2.  $En = V_{SS}$ , all other inputs =  $V_{DR}$  or  $V_{SS}$ .

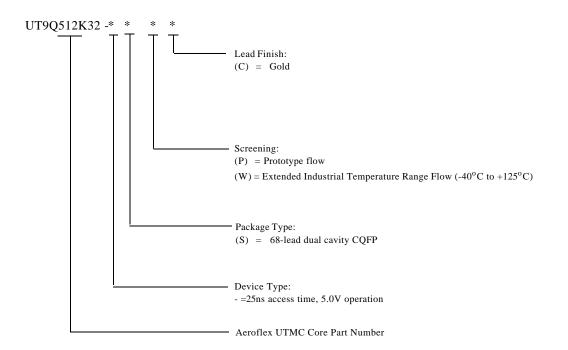
3. Not guaranteed or tested.

### PACKAGING



### **ORDERING INFORMATION**

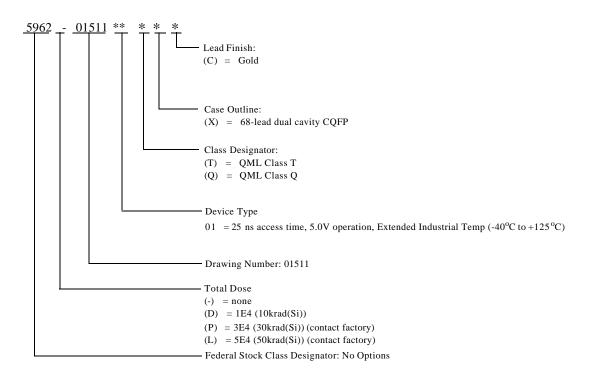
### 512K32 16Megabit SRAM MCM:



Notes:

- Prototype flow per UTMC Manufacturing Flows Document. Devices are tested at 25°C. Gold lead finish only.
   Extended Industrial Temperature Range flow per UTMC Manufacturing Flows Document. Devices are tested at -40°C to +125°C. Radiation neither tested nor guaranteed. Gold Lead Finish Only.

#### 512K32 16Megabit SRAM MCM: SMD



Notes:

1. Total dose radiation must be specified when ordering. Gold finish only.

2. Only Extended Industrial temperature -40C to +125C. No military temp. test available.